			in
	Application No.	Applicant(s)	;(MC
Notice of Allowability	10/045,354	HUI ET AL.	
	Examiner	Art Unit	
	Khiem D Nguyen	2823	
The MAILING DATE of this communication appear All claims being allowable, PROSECUTION ON THE MERITS IS herewith (or previously mailed), a Notice of Allowance (PTOL-85) NOTICE OF ALLOWABILITY IS NOT A GRANT OF PATENT RISE of the Office or upon petition by the applicant. See 37 CFR 1.313 1. This communication is responsive to 07/01/04. 2. The allowed claim(s) is/are 1-7 and 9-24. 3. The drawings filed on 07 November 2001 are accepted by 4. Acknowledgment is made of a claim for foreign priority und a) All b) Some* c) None of the: 1. Certified copies of the priority documents have 2. Certified copies of the priority documents have 3. Copies of the certified copies of the priority documents have International Bureau (PCT Rule 17.2(a)). * Certified copies not received: 5. Acknowledgment is made of a claim for domestic priority und a Capital anguage provisional and the foreign language provisional and the foreign languag	(OR REMAINS) CLOSED in or other appropriate commu (GHTS. This application is stand MPEP 1308. the Examiner. Her 35 U.S.C. § 119(a)-(d) or been received. been received in Application cuments have been received and a standard sta	this application. If not inclusinication will be mailed in duction will be mailed in duction withdrawal from issuit of the control of the con	ded e course. THIS sue at the initiative
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Applicant has THREE MONTHS FROM THE "MAILING DATE" of pelow. Failure to timely comply will result in ABANDONMENT of the submover of the submover of the submover of the submover of the submove of the su	his application. THIS THRE	EE-MONTH PERIOD IS NOT	EXTENDABLE
 CORRECTED DRAWINGS must be submitted. (a) ☐ including changes required by the Notice of Draftspers 1) ☐ hereto or 2) ☐ to Paper No (b) ☐ including changes required by the proposed drawing or 			
 (b) ☐ including changes required by the proposed drawing c (c) ☐ including changes required by the attached Examiner's 	s Amendment / Comment or	in the Office action of Paper	· No
Identifying indicia such as the application number (see 37 CFR 1.6 each sheet.	84(c)) should be written on the	drawings in the front (not the	e back) of
 DEPOSIT OF and/or INFORMATION about the deposit attached Examiner's comment regarding REQUIREMENT FOR THE 	it of BIOLOGICAL MATE HE DEPOSIT OF BIOLOGIC	RIAL must be submitted. AL MATERIAL.	Note the
Attachment(s)			
 ☑ Notice of References Cited (PTO-892) ☐ Notice of Draftperson's Patent Drawing Review (PTO-948) ☑ Information Disclosure Statements (PTO-1449), Paper No. 11 ☐ Examiner's Comment Regarding Requirement for Deposit of Biological Material 	4☐ Interview <u>03</u> . 6⊠ Examiner'	Informal Patent Application (Summary (PTO-413), Paper 's Amendment/Comment 's Statement of Reasons for	No

Application/Control Number: 10/045,354

Art Unit: 2823

EXAMINER'S AMENDMENT

An examiner's amendment to the record appears below. Should the changes and/or additions be unacceptable to applicant, an amendment may be filed as provided by 37 CFR 1.312. To ensure consideration of such an amendment, it MUST be submitted no later than the payment of the issue fee.

Authorization for this examiner's amendment was given in a telephone interview with Mr. Eric Highman (Reg. No. 43,672) on July 1st, 2004.

The application has been amended as follows:

In claim:

Cancel claims 8 and 27.

In independent claim 1, line 6, after "completely", insert -- from the gaps--.

In independent claim 10, line 6, after "completely", insert -- from the gaps--.

In independent claim 19, line 7, after "process", insert --wherein plasma etching completely removes the sacrificial material from the gaps--.

In independent claim 21, line 10, after "the hard mask layer", insert --from the gap--.

In independent claim 24, lines 11-12, after "the hard mask layer", insert --from the gap--.

Allowable Subject Matter

Claims 1-7 and 9-24 are allowed.

Application/Control Number: 10/045,354

Art Unit: 2823

Reasons For Allowance

The following is a statement of reasons for the indication of allowable subject matter: The prior art taken alone or in combination neither discloses nor makes obvious the instant process of claims as a whole. Specifically, the prior art of record, Cheng et al. (U.S. Patent 6,159,821) discloses a method of stripping a hard mask from a substrate comprising an insulating material (FIG. 2: 12) (col. 2, lines 34-36) exposed within gaps (FIG. 2: 16) (col. 2, lines 33-44) patterned through the hard mask (FIG. 2: 14), comprising (col. 2, line 33 to col. 3, line 51 and FIGS. 1-11): coating the substrate (FIG. 2: 10) with an oxide layer (FIGS. 3-4: 17) that fills the gaps (col. 2, lines 45-48); and dry etching (col. 2, lines 54-64) to strip the oxide layer and the hard mask (FIGS. 4-5) such that an oxide portion remains in the gaps but fails to teach or suggest the Applicant's steps of coating the substrate with a sacrificial material that fills the gaps; and plasma etching to strip the sacrificial material and the hard mask substantially completely from the gaps in a single plasma etch process as recited in the independent claims.

Any comments considered necessary by applicant must be submitted no later than the payment of the issue fee and, to avoid processing delays, should preferably accompany the issue fee. Such submissions should be clearly labeled "Comments on Statement of Reasons for Allowance."

Conclusion

Any inquiry concerning this communication or earlier communications from the examiner should be directed to Khiem D Nguyen whose telephone number is (571) 272-1865. The examiner can normally be reached on Monday-Friday (8:00 AM - 5:00 PM).

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Olik Chaudhuri can be reached on (571) 272-1855. The fax phone numbers for the organization where this application or proceeding is assigned are (703) 305-3432 for regular communications and (703) 305-3432 for After Final communications.

Any inquiry of a general nature or relating to the status of this application or proceeding should be directed to the receptionist whose telephone number is (703) 308-0956.

K.N. July 7, 2004

W. DAVID COLEMAN PRIMARY EXAMINER